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# Crystal structure and fluoride-ion conductivity of strontium cerium fluoride epitaxial films prepared by topochemical fluorination†

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**Topochemical fluorination of perovskite SrCeO<sub>3</sub> epitaxial thin films using polyvinylidene difluoride was performed at different annealing temperatures ( $T_f$ ) for 1 h. Fluorite Sr<sub>0.5</sub>Ce<sub>0.5</sub>F<sub>2.5</sub> epitaxial thin films were obtained at  $T_f > 350$  °C, which exhibited fluoride-ion conductivity with an activation energy of 0.61 eV.**

Lithium-ion batteries are presently utilized in a variety of devices ranging from smartphones to electric vehicles. However, the risk of lithium ignition and concerns about long-term supply stability have led to the development of rechargeable batteries using alternative elements. Among them, fluoride-ion batteries (FIBs) are attracting considerable attention owing to their high theoretical energy densities and utilization of fluorine, which is abundant compared to lithium.<sup>1–3</sup> FIBs have higher gravimetric and volumetric energy densities than lithium-ion and sodium-ion batteries, enabling the production of lighter and smaller batteries.<sup>1,2</sup> Moreover, fluoride ions are highly redox-stable, which provides a wide electrochemical

potential window for FIBs to deliver high open circuit voltages.<sup>2</sup> However, FIBs also exhibit poor charging and discharging characteristics and relatively high operating temperatures; hence, further fundamental research, including development of new solid-state electrolyte materials, is required to improve the performance of FIBs.

Metal fluorides, alkaline earth fluorides (AF<sub>2</sub>) with a fluorite structure ( $Fm\bar{3}m$ ), and rare earth fluorides (RF<sub>3</sub>) with a tysonite structure ( $P\bar{3}c1$ ), are considered as solid electrolytes for FIBs owing to their fast F-ion conductivities.<sup>4,5</sup> Partial cation substitution increases the number of permanent defects in the structure and facilitates fluoride migration, significantly increasing the fluoride conductivity of these solids. For example, tysonite-type Ce<sub>0.95</sub>Ca<sub>0.05</sub>F<sub>2.95</sub> and Ce<sub>0.975</sub>Sr<sub>0.025</sub>F<sub>2.975</sub> are fast fluoride-ion conductors with ionic conductivities of  $\sim 10^{-2}$  S cm<sup>-1</sup> at 573 K and  $3 \times 10^{-4}$  S cm<sup>-1</sup> at room temperature,<sup>6,7</sup> respectively.

Several methods are available for the synthesis of metal fluorides, including solid phase reactions,<sup>8</sup> hydrothermal synthesis,<sup>9</sup> melt growth techniques,<sup>10</sup> and fluorination reactions of metal compound precursors with gaseous agents such as F<sub>2</sub> and HF.<sup>11</sup> Recently, thin films of fluorite-type Ba<sub>0.5</sub>Bi<sub>0.5</sub>F<sub>2.5</sub> were synthesized by topochemical fluorination of perovskite-type BaBiO<sub>3</sub> precursor films using polyvinylidene fluoride (PVDF), and a maximum conductivity of  $3.4 \times 10^{-7}$  S cm<sup>-1</sup> at 353 K was achieved.<sup>12,13</sup> In general, single-crystalline thin films of metal oxyfluorides or fluorides without undesired impurity phases can be prepared through PVDF-mediated topochemical fluorination of metal oxides.<sup>12–15</sup>

Single-crystal epitaxial films are useful for studying the physical properties of Ce fluorides, which are promising fluoride ion conductors. Since Ce ions exist stably in the crystal as either Ce<sup>3+</sup> or Ce<sup>4+</sup>, reductive fluorination of perovskite SrCeO<sub>3</sub> (SCO) epitaxial films with PVDF (which acts as a reducing agent<sup>12</sup>) can be used to fabricate epitaxial films. In this study, we performed PVDF-mediated topochemical fluorination of perovskite SCO thin films and investigated the crystal structures and fluoride-ion conductivities of the obtained films.

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† Electronic supplementary information (ESI) available: Reciprocal space mapping images of the SrCeO<sub>3</sub> precursor and the film fluorinated at  $T_f = 500$  °C, lengths of the *a*- and *c*-axes of the precursor and fluorinated films, cross-sectional STEM images and STEM-EDS color maps, schematic of the fluorite crystal structure of Sr<sub>0.5</sub>Ce<sub>0.5</sub>F<sub>2.5</sub>, and in-plane and out-of-plane impedance spectra and the fitting results of the Sr<sub>0.5</sub>Ce<sub>0.5</sub>F<sub>2.5</sub> film. See DOI: <https://doi.org/10.1039/d5cc00985e>



Perovskite SCO precursor films were grown on nonconductive SrTiO<sub>3</sub> (100) (STO) and conductive 0.5 wt% Nb-doped STO (Nb:STO) substrates (Shinkosha Co.) by pulsed-laser deposition. The fourth harmonic of a Nd-doped yttrium aluminium garnet laser (wavelength  $\lambda = 266$  nm) with an energy of 1.9 J per cm<sup>2</sup> per shot and a repetition rate of 5 Hz was used as the laser source. The films were deposited at an oxygen partial pressure and substrate temperature of  $1 \times 10^{-5}$  Torr and 750 °C, respectively. The as-deposited SCO films were annealed at different temperatures ( $T_f = 100$ –550 °C) in a tube furnace with the PVDF powder (Fluorochem Ltd.) placed upstream. Ar was used as the carrier gas for fluorination, and the temperature rise time was 1 h. The film thickness, as measured using a stylus surface profiler (Veeco Dektak 6 M), was 60–80 nm.

The crystal structures of the films were examined using X-ray diffraction (XRD; Bruker AXS D8 Discover; Cu K $\alpha$  radiation) and scanning transmission electron microscopy (STEM) with energy dispersive X-ray spectroscopy (EDS; JEM-ARM200F-B, JEOL) operated at an acceleration voltage of 200 kV. A focused ion beam instrument (NB5000, Hitachi High-Tech) was used to prepare thin samples for the STEM measurements. The chemical compositions of the films were investigated by scanning electron microscopy–energy dispersive X-ray spectroscopy (SEM-EDS; JEOL JSM-7100F and JED-2300, respectively). The core-level spectra of the films at 300 K were obtained using X-ray photoemission spectroscopy (XPS) with an Al K $\alpha$  X-ray source and a charge-neutralizing flood gun (Thermo Fisher Scientific K-Alpha). The Fermi level was calibrated against the C 1s signal. The in-plane and out-of-plane F-ion conductivities were obtained using AC impedance measurements at 5 MHz–10 MHz and 5 MHz–10 Hz, respectively. An in-plane electrode was comb-shaped Pt patterns sputtered onto the film using a SUS shadow mask. Out-of-plane measurements used a 200- $\mu$ m Pt top electrode and the Nb:STO substrate as the bottom electrode, respectively. The schematic diagrams of the crystal structures were drawn using the VESTA software.<sup>16</sup>

Fig. 1 shows the XRD patterns of the SCO precursor film and fluorinated films. The XRD pattern of the precursor film exhibited peaks corresponding to (001) and (002) planes of perovskite SCO at  $2\theta = 20.7$  and  $42.1^\circ$ , respectively. The XRD patterns were unchanged at  $T_f \leq 200$  °C, indicating that PVDF did not react with the SCO film up to 200 °C. The films fluorinated at  $T_f = 250$  °C exhibited a new peak at  $2\theta = 31.7^\circ$ , which corresponds to the 002 plane of the fluorite structure. Thus, the perovskite and fluorite structures were mixed at  $T_f = 250$  °C. At  $T_f = 300$  °C, two additional peaks appeared at  $2\theta = 30.5$  and  $63.4^\circ$ , respectively. At  $T_f > 350$  °C, the diffraction peaks of perovskite SCO ( $2\theta = 20.7$  and  $42.1^\circ$ ) and fluorite ( $2\theta = 31.7^\circ$ ) disappeared, indicating that the film was completely transformed into the fluorite structure.

Fig. 2(a) and (b) show the cross-sectional annular dark-field scanning transmission electron microscopy (STEM) images of the SCO precursor film and fluorinated film ( $T_f = 500$  °C) taken along [100] and [110] axes, respectively. The perovskite structure of SCO and fluorite structure of Sr<sub>0.5</sub>Ce<sub>0.5</sub>F<sub>2.5</sub> (SCF) were clearly observed. Fig. 2(c) and (d) show the STEM–EDS maps colorized after using wavelet-

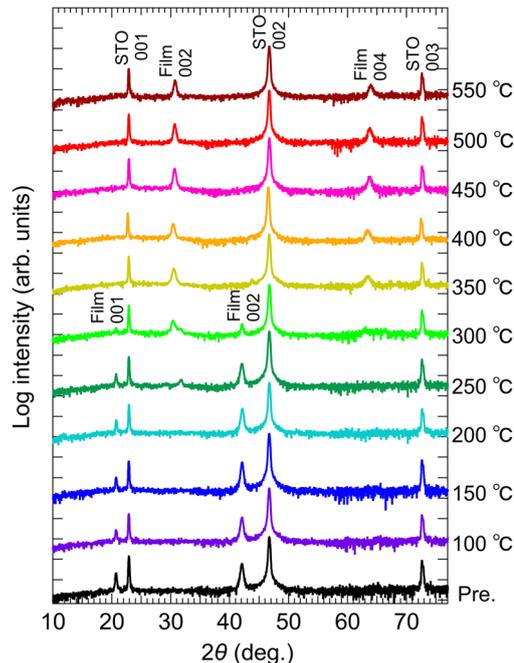


Fig. 1 X-ray diffraction patterns of the SrCeO<sub>3</sub> precursor film and films fluorinated at  $T_f = 100$ –550 °C for 1 h.

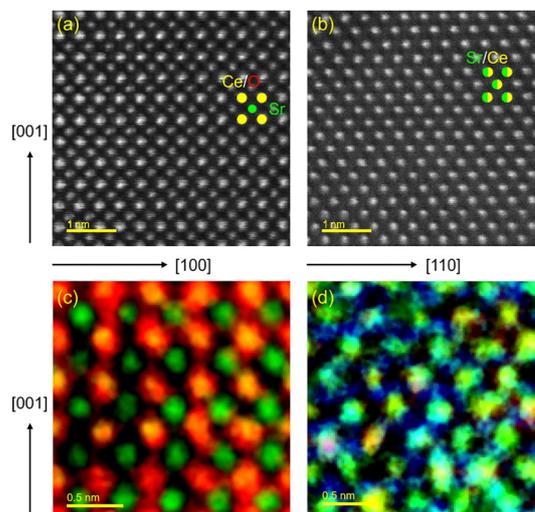


Fig. 2 Cross-sectional annular dark-field scanning transmission electron microscopy (STEM) images of the (a) SrCeO<sub>3</sub> precursor film and (b) film fluorinated at  $T_f = 500$  °C, taken along [100] and [110] axes, respectively. STEM–energy dispersive spectroscopy maps of the (c) SCO precursor film and (d) film fluorinated at  $T_f = 500$  °C, colorized after using wavelet-transform-inspired image processing techniques (Sr: green, Ce: yellow, O: red, and F: blue).

transform-inspired image processing techniques.<sup>17</sup> In Fig. 2(c), the positions of Ce and Sr are significantly different, with O appearing to be more abundant in the region that overlaps Ce. This arrangement corresponds to that of the perovskite structure. In contrast, Fig. 2(d) shows the coexistence of Ce and Sr at



the same site, albeit with different mixing patterns. In addition, F is mostly present in the interlayer but also observed in the Ce/Sr layer. These results indicate that the topochemical fluorination completely replaced oxygen with fluorine and migrated the cations, resulting in the fluorite structure.

Fig. S1 (ESI<sup>†</sup>) shows the reciprocal space mapping images around the 103 asymmetric diffraction of the SrCeO<sub>3</sub> precursor film and film fluorinated at  $T_f = 500$  °C, indicating preserved epitaxy after fluorination. Fig. S2 (ESI<sup>†</sup>) shows the plots of the lengths of the *a*- and *c*-axes of the SCO precursor film and fluorinated films (obtained from the XRD measurements) as a function of  $T_f$ . The *c*-axis length significantly increased with change in the structure from perovskite to fluorite, while the *a*-axis length decreased. In addition, two different lattice constants were identified for the fluorite structure at  $T_f = 300$  °C.

As mentioned above, the perovskite and fluorite structures with two different lattice constants were mixed at  $T_f = 250$ – $300$  °C. Therefore, we observed the STEM-EDS of the SCO film fluorinated at 250 °C with a temperature rise time of 1 h (Fig. S2, ESI<sup>†</sup>). In the region of Fig. S2(a–c) (ESI<sup>†</sup>), Ce and Sr are present at different sites, and the structure is basically perovskite SCO, but F is also present between the lattices. In the region of Fig. S2(d–f) (ESI<sup>†</sup>), Ce and Sr are present at the same sites, F is in the interlayer, and the structure is basically fluorite SCF; however, O is found near the cation sites in some areas. These observations suggest that the XRD peaks ( $2\theta = 31.7^\circ$ ) of the film fluorinated at  $T_f = 250$ – $300$  °C (Fig. 1) originated from oxyfluoride with a fluorite structure.

Fig. 3(a) shows the EDS spectra (at an acceleration voltage ( $V_a$ ) of 2.5 kV) of the SCO precursor film and fluorinated films, where the spectra were normalized to the Ce  $M\alpha$  peaks. While the EDS spectra were unchanged at  $T_f < 200$  °C, the F  $K\alpha$  peak appeared (0.67 keV) at  $T_f > 250$  °C. The intensity of the F  $K\alpha$  peak significantly increased at  $T_f > 350$  °C, whereas the O  $K\alpha$  peak almost disappeared. These results confirm the removal of oxygen ions in the SCO film and the incorporation of fluorine

ions *via* fluorination with PVDF. Fig. 3(b) shows the Ce 3d X-ray photoelectron spectra of the SCO precursor film and films fluorinated at 150 and 400 °C for 1 h. Compared with the reference spectra of Ce<sup>4+</sup>O<sub>2</sub> and Ce<sup>3+</sup>PO<sub>4</sub>, the precursor film and film fluorinated at 150 °C consist of Ce<sup>4+</sup>, and the film fluorinated at 400 °C consists of Ce<sup>3+</sup>.<sup>18</sup> Therefore, the chemical composition of the film fluorinated at  $T_f > 350$  °C is determined as Sr<sub>0.5</sub><sup>2+</sup>Ce<sub>0.5</sub><sup>3+</sup>F<sub>2.5</sub>.

In our previous work on the topochemical fluorination of a BaBiO<sub>3</sub> thin film at 200 °C for 24 h, the 001 superlattice peak was observed in the XRD pattern, which indicated the ordering of the Ba and Bi cations perpendicular to the film plane.<sup>12</sup> However, in the present study, the 001 superlattice peak was not observed in the XRD patterns. Furthermore, the STEM-EDS of the SCF film revealed the coexistence of Ce and Sr at the same site, as shown in Fig. 2(d). Fig. 4 shows the change in the crystal structure of the SCO film with PVDF-mediated fluorination. The [100] direction of the perovskite SCO film corresponds to the [110] direction of the fluorite SCF film. A schematic of the fluorite crystal structure of Sr<sub>0.5</sub>Ce<sub>0.5</sub>F<sub>2.5</sub> from different angles is shown in Fig. S4 (ESI<sup>†</sup>). When fluorinated above 350 °C, oxygen ions in the perovskite structure are removed, and fluorine ions occupy the anion sites of the fluorite structure.

Topochemical fluorination reactions of many transition-metal oxide thin films using PVDF have been reported, but the reaction times are ~10 h or longer.<sup>14,15</sup> For example, in the topochemical fluorination of NdNiO<sub>3</sub> thin films, time-dependent XRD experiments have confirmed that the reaction takes 24 h at 350 °C to progress completely.<sup>15</sup> However, in the present study, the SCO thin film transitioned to the fluorite structure within 1 h at 350 °C, which is a considerably faster heating time. This indicates that SCO has an unusually high reactivity during topochemical fluorination with PVDF.

To investigate the F-ion conductivity of the SCF thin films, in-plane and out-of-plane impedance spectra of the SCF film obtained at  $T_f = 500$  °C were measured at 323–523 K and 323–443 K, as shown in Fig. S5 and S6 (ESI<sup>†</sup>), respectively. All the impedance spectra were composed of a semicircle at high frequencies and straight line at low frequencies, and these were observed at higher frequencies as the temperature increased. The semicircle and straight-line portions of each spectrum are attributed to F-ion conduction in the film (intra- and inter-granular) and at the film/electrode interface, respectively. Fig. 5 shows the in-plane and out-of-plane F-ion conductivity of the

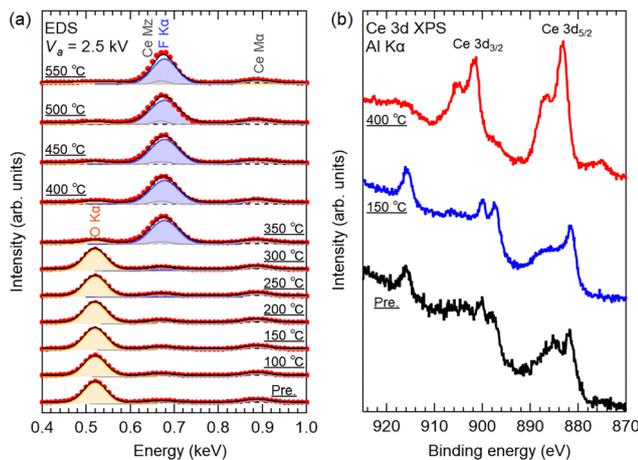


Fig. 3 (a) Energy dispersive X-ray spectra (at  $V_a = 2.5$  kV) of the SrCeO<sub>3</sub> precursor film and fluorinated films. (b) Ce 3d X-ray photoelectron spectra of the SrCeO<sub>3</sub> precursor film and the films fluorinated at 150 and 400 °C for 1 h.

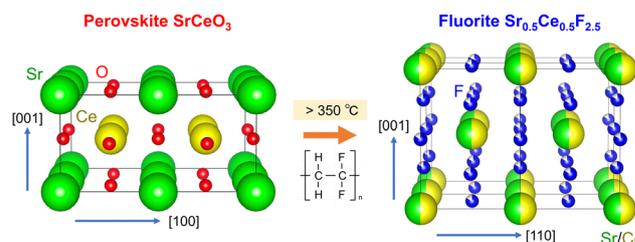


Fig. 4 Schematic of the change in crystal structure of the SrCeO<sub>3</sub> film with polyvinylidene fluoride-mediated fluorination.



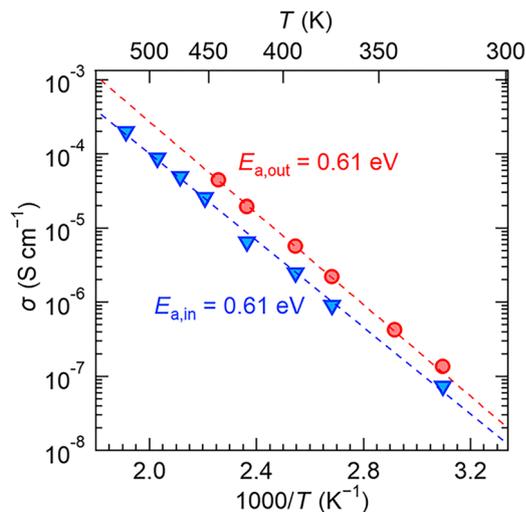


Fig. 5 In-plane (blue) and out-of-plane (red) F-ion conductivity of the  $\text{Sr}_{0.5}\text{Ce}_{0.5}\text{F}_{2.5}$  film obtained at  $T_f = 500$  °C as a function of temperature. The dashed line represents the linear fit of the measurements.

SCF film obtained at  $T_f = 500$  °C as a function of temperature, calculated from the impedance spectra in Fig. S5 and S6 (ESI†). The in-plane F-ion conductivity was smaller than the out-of-plane conductivity. For example, the F-ion conductivities at 323 K were  $7.4 \times 10^{-8}$  S  $\text{cm}^{-1}$  (in-plane) and  $1.4 \times 10^{-7}$  (out-of-plane), respectively. The Arrhenius plot was fitted with a straight line over the measured temperature range, and both the in-plane and out-of-plane activation energies ( $E_{a,\text{in}}$  and  $E_{a,\text{out}}$ ) were estimated to be almost the same value: 0.61 eV. This value is larger than the activation energy of polycrystalline  $\text{Ce}_{0.975}\text{Sr}_{0.025}\text{F}_{2.975}$  (0.31 eV), a high F-ion conductor of cerium fluoride.<sup>7</sup> The reason for this difference may be due to the difference in crystal structure. In the future, the ionic conductivity and  $E_a$  could be improved by modulating the crystal structure through adjusting the amount of cation dopants or F carriers.

In summary, we performed topochemical fluorination of perovskite SCO epitaxial thin films using PVDF at  $T_f = 100$ – $550$  °C for 1 h. Single-phase SCF epitaxial thin films with a fluorite-type structure were obtained at  $T_f > 350$  °C. In addition, the SCF thin film exhibited an out-of-plane F-ion conductivity of  $1.4 \times 10^{-7}$  S  $\text{cm}^{-1}$  at 323 K with an activation energy of 0.61 eV. The synthesis of cerium fluoride thin films *via* PVDF-mediated topochemical fluorination would provide new F-ion conductors for use as solid electrolytes in FIBs.

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## Data availability

The data supporting the findings of this study are available within the article or its ESI.†

## Conflicts of interest

There are no conflicts to declare.

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